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# Interfacial band alignment and photoelectrochemical properties of all-sputtered BiVO<sub>4</sub>/FeNiO<sub>x</sub> and BiVO<sub>4</sub>/FeMnO<sub>x</sub> p–n heterojunctions†

Andressa S. Correa,<sup>‡a</sup> Lucas G. Rabelo,<sup>‡a</sup> Washington S. Rosa,<sup>a</sup> Niqab Khan,<sup>ab</sup> Satheesh Krishnamurthy,<sup>‡c</sup> Sherdil Khan<sup>‡d</sup> and Renato V. Gonçalves<sup>‡\*a</sup>

BiVO<sub>4</sub> is a well-known n-type semiconductor with great potential for photoelectrochemical (PEC) conversion of solar energy into chemical fuels. Nevertheless, photocurrent densities achieved for bare BiVO<sub>4</sub> photoanodes are still far from their theoretical maximum due to the sluggish water oxidation kinetics and limitation in electron-hole recombination. In this work, magnetron sputtering deposition was used for depositing FeMO<sub>x</sub> (M = Ni, Mn) as cocatalyst layers to induce p–n heterojunctions and suppress charge recombination on BiVO<sub>4</sub> photoanodes. The all-sputtered p–n heterojunction BiVO<sub>4</sub>/FeMnO<sub>x</sub> exhibited the highest photocurrent density (1.25 mA cm<sup>-2</sup> at 1.23 V vs. RHE) and excellent chemical stability, indicating that the combination of Mn sites on Fe-based oxides provides promising cocatalytic materials for PEC applications. Experimental and theoretical techniques were used to investigate the interfacial band alignment and charge transport properties of BiVO<sub>4</sub>/FeMO<sub>x</sub> (M = Ni, Mn) heterojunctions. Our results show that type II heterojunctions arise in the BiVO<sub>4</sub>/FeMO<sub>x</sub> (M = Ni, Mn) interface after equilibrium, thereby providing potential barriers to inhibit electron flow from the BiVO<sub>4</sub> to the FeMO<sub>x</sub> layers. Furthermore, the BiVO<sub>4</sub>/FeMnO<sub>x</sub> film showed a larger space charge region (SCR) characterized by a more intense built-in electric field than BiVO<sub>4</sub>/FeNiO<sub>x</sub>, explaining its higher PEC performance. In summary, this work provides a viable technique for producing photocatalytic heterojunction systems based on metal oxide semiconductors and introduces simple tools for investigating interface effects on photoinduced charge carrier pathways for PEC applications.

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## Introduction

Recently, photoelectrochemical (PEC) water splitting has attracted much attention due to its potential to provide a zero-emission pathway for hydrogen production. Typically, the PEC process involves an oxygen evolution reaction (OER) and a hydrogen evolution reaction (HER), which take place at the photoelectrode and counter electrode, respectively.

The practical application of PEC is still challenging because of the availability of a suitable photoelectrode that can absorb a large portion of light, effectively separate charge, and have high surface reactivity. Among various developed photoanode materials, bismuth vanadate (BiVO<sub>4</sub>) has been widely regarded as a promising photoanode for converting solar energy into chemical fuels in photoelectrochemical (PEC) cells, showing visible light activity.<sup>1</sup> The scheelite-monoclinic BiVO<sub>4</sub> exhibits narrow bandgap energy (~2.4–2.5 eV), with suitable band edge positions for water oxidation, earth-abundant composition, non-toxicity, and modest chemical stability in neutral electrolytes.<sup>2,3</sup> Nevertheless, photocurrent densities measured for unmodified BiVO<sub>4</sub> films are still significantly lower than the theoretical maximum value of 7.5 mA cm<sup>-2</sup> (under AM 1.5G illumination) due to its fast electron-hole recombination and sluggish water reaction kinetics.<sup>4</sup> As a result, several strategies have been employed to overcome these main limitations, including but not limited to doping with tungsten<sup>5</sup> or molybdenum,<sup>6</sup> depositing cocatalysts such as Co-Pi,<sup>7</sup> FeCoO<sub>x</sub>,<sup>8</sup> and FeNiO<sub>x</sub>,<sup>9</sup> and forming anisotype heterojunctions.<sup>10,11</sup>

<sup>a</sup> São Carlos Institute of Physics, University of São Paulo, PO Box 369, 13560-970 São Carlos, SP, Brazil. E-mail: rgoncalves@ifsc.usp.br

<sup>b</sup> Laboratory of Nanomaterials for Renewable Energy and Artificial Photosynthesis (NanoREAP), Federal University of Rio Grande do Sul (UFRGS), Campus do Vale, Agronomia, Porto Alegre-RS, Brazil

<sup>c</sup> School of Engineering and Innovation, The Open University, Milton Keynes, MK7 6AA, UK

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‡ Andressa S. Correa and Lucas G. Rabelo contributed equally to this paper.



Surface modification of BiVO<sub>4</sub> films with metal oxide cocatalysts has been an essential strategy for accelerating the surface reaction kinetics and suppressing charge carrier recombination.<sup>12,13</sup> Recently, iron-based bimetallic oxides have been established as low-cost and efficient cocatalysts for the oxygen evolution reaction (OER).<sup>8,9,14,15</sup> For instance, Wang *et al.* synthesized BiVO<sub>4</sub>/FeCoO<sub>x</sub> films with an AM 1.5G photocurrent density of 4.82 mA cm<sup>-2</sup> at +1.23 V vs. RHE and with excellent chemical stability.<sup>8</sup> Similarly, Zhang *et al.* deposited FeNiO<sub>x</sub> cocatalyst onto boron-treated BiVO<sub>4</sub> films, achieving a high photocurrent of 5.22 mA cm<sup>-2</sup> at +1.23 V vs. RHE.<sup>9</sup> X. Du *et al.* have also fabricated Fe<sup>0</sup>/MnO<sub>x</sub>/BiVO<sub>4</sub> ternary magnetic assemblies using hydrothermal and photodeposition techniques that have shown a considerable increase in photocatalytic activity.<sup>16</sup> Similarly, M sun *et al.* have developed manganese-based oxygen evolution catalysts, achieving a high current density of 4.85 mA cm<sup>-2</sup> at +1.23 V vs. RHE.<sup>17</sup> Besides the enhanced surface reaction kinetics, the heterojunction arising at the semiconductor/cocatalyst interface is essential to improve PEC performance. In particular, developing p-n heterojunctions has been widely applied for engineering the charge transport properties of semiconductor materials by inducing an interfacial built-in electric field that may assist in charge carrier separation and transport.<sup>18</sup> Remarkably, charge separation efficiencies of about 90% have already been obtained after the deposition of p-type layers on the surface of bare BiVO<sub>4</sub> films.<sup>8</sup>

Despite its recent efforts, most of the current PEC research examines an enhanced performance of heterojunctions utilizing flat band alignment diagrams derived from individual semiconductor information. This strategy completely ignores the interface effects that might occur during the formation of heterojunctions (*i.e.*, band bending and built-in electric field) and provides no solid insights into charge transport properties in such materials, easily inducing misleading interpretations.<sup>19–21</sup> Besides these, it remains uncertain how the interface affects the PEC activity of BiVO<sub>4</sub>-based heterojunctions, exemplified by inconsistent directions of charge flow as reported in several publications for BiVO<sub>4</sub>/WO<sub>3</sub> films.<sup>21,22</sup> These issues highlight the importance of establishing reliable tools for capturing interface effects on heterojunctions utilizing information from both individual semiconductors and heterostructured material. In this context, the X-ray Photoelectron Spectroscopy (XPS) technique has been widely employed to determine the valence band offset (through Kraut's method<sup>23</sup>) and built-in potentials of heterostructured systems,<sup>24,25</sup> thereby directly determining its interfacial band alignment and charge transport properties.

Herein, motivated by the promise of BiVO<sub>4</sub>-based p-n heterojunctions for PEC applications and to answer the fundamental questions on interfaces, this work aims to provide a deep and comprehensive investigation of the influence of interfacial effects of BiVO<sub>4</sub>/FeMO<sub>x</sub> (M = Ni, Mn) heterojunctions on PEC water oxidation performance. To this end, we employed a well-established RF-magnetron sputtering technique to deposit *n*-type BiVO<sub>4</sub> film from a homemade ceramic sputtering

target and two *p*-type iron-based binary oxides {FeMO<sub>x</sub> (M = Ni, Mn)} cocatalysts for the first time to our knowledge. The interfacial band alignment and charge transport properties of BiVO<sub>4</sub>/FeNiO<sub>x</sub> and BiVO<sub>4</sub>/FeMnO<sub>x</sub> heterojunctions were examined using XPS spectroscopy, Mott-Schottky analysis, UV-vis spectroscopy, and the classical band bending model. Our results indicated that the BiVO<sub>4</sub>/FeMnO<sub>x</sub> interface produces a larger space charge region (SCR) than the BiVO<sub>4</sub>/FeNiO<sub>x</sub>, resulting in a more intense built-in electric field that readily accelerates the photogenerated charge carriers. This result is supported by the higher photocurrent densities and chemical stability of the BiVO<sub>4</sub>/FeMnO<sub>x</sub> heterojunction in PEC measurements. In summary, our study provides a viable technique for producing new heterojunction systems and illustrates how band energy alignment based on flat diagrams leads to misleading interpretations. In this work, we also introduce FeMnO<sub>x</sub> as a novel efficient cocatalyst for surface modification of *n*-type semiconductors applied to PEC water oxidation.

## Experimental section

All chemicals were of analytical grade and were used as received without further purification. Fluorine-doped tin oxide (FTO) coated glass substrate with a surface resistivity of 7.0 Ω sq<sup>-1</sup> was purchased from Sigma-Aldrich Ltda.

### Deposition of BiVO<sub>4</sub> and bimetallic oxides FeMO<sub>x</sub> (M = Ni, Mn) films

RF-magnetron sputtering with a 2-inch homemade BiVO<sub>4</sub> ceramic target was used to deposit BiVO<sub>4</sub> (BVO) films on the surface of a cleaned FTO substrate at several deposition intervals (from 3 to 30 minutes). Details on the BiVO<sub>4</sub> ceramic target fabrication can be found in the ESI.† All depositions were carried out at a constant operating distance of 5.0 cm between the targets and FTO substrates. Prior to the initial deposition of the BiVO<sub>4</sub> target, a 30 minutes pre-sputtering deposition was performed to ensure that any potential contaminants on the surface of the target (such as adventitious carbon species) were removed. The base pressure and working pressure of the sputtering chamber for all deposition were set to 7.5 × 10<sup>-6</sup> and 3.2 × 10<sup>-2</sup> Torr, respectively. The composition of the working pressure was a mixture of argon and oxygen gases (18.5 Ar scm and 2.1 O<sub>2</sub> scm), and the RF power was set to 50 W for all deposition. After deposition, the BiVO<sub>4</sub> film was annealed in an air atmosphere at 400 °C for 1 h, resulting in a crystalline film named BVO. Finally, a FeNiO<sub>x</sub> or FeMnO<sub>x</sub> thin layer was deposited over the BVO film using different metal alloy targets: FeMn (50 wt% Fe and 50 wt% Mn, 99.9% purity) and FeNi (50 wt% Fe and 50 wt% Ni, 99.9% purity), with an Ar/O<sub>2</sub> (18.5:2.1 scm) working pressure of 4.0 × 10<sup>-2</sup> torr and deposition times ranging from 30 to 120 seconds. Importantly, the deposition rate for the BiVO<sub>4</sub> film was adjusted to 10.06 nm min<sup>-1</sup>, whereas the deposition rates for the FeNiO<sub>x</sub> and FeMnO<sub>x</sub> were 1.37 and 0.94 nm min<sup>-1</sup>, respectively.



### Characterization

X-ray diffraction (XRD) was used to investigate the structural properties of BiVO<sub>4</sub> films (Rigaku Ultima IV diffractometer) with a Cu K $\alpha$  radiation with  $2\theta$  angle from 10° to 80° and a step scan of 0.02°. Raman spectra were obtained using a WITec alpha 300 equipped with a linear stage, piezo-driven, objective lens Nikon 20 $\times$  (NA = 0.46) and polarized laser with 514 nm wavelengths. Scanning electron microscopy (SEM) was used to investigate the morphology of the samples (Zeiss Sigma Gemini model field emission microscope operating at an accelerating voltage of 20 kV). The thicknesses of the BiVO<sub>4</sub> and FeMO<sub>x</sub> (M = Ni, Mn) films were measured in a surface profilometer (Dektak 150, Veeco). UV-vis absorption measurements of the BiVO<sub>4</sub> films were performed using a Shimadzu UV-2600 spectrometer fitted with an integrating sphere. Surface composition was analyzed by X-ray photoelectron spectroscopy (XPS) using a Scienta-Omicron ESCA+ spectrometer with a monochromatic Al K $\alpha$  ( $h\nu = 1486.6$  eV) radiation source. The XPS spectra were recorded at a pass energy of 30 eV with a 0.05 eV per step. Charging effects were eliminated using a low-energy electron flood gun. Adventitious carbon (C 1s) at 284.8 eV was used to calibrate the XPS spectra. Data analysis was performed using CasaXPS software using a Shirley-type background subtraction before the curve fitting. The high-resolution valence band XPS spectra were measured by linear extrapolation of the data to zero intensity, and the Fermi level of the sample corresponds to 0 eV on the binding energy axis (by definition).

### Photoelectrochemical measurements

Photoelectrochemical performance of photoanodes was carried out using a three-electrode configuration with the Autolab (PGSTAT128N) electrochemical workstation. The BVO-based thin films were used as a working electrode (area: 1 cm<sup>2</sup>), Ag/AgCl as the reference electrode and a platinum bar as the counter electrode. All PEC measurements were performed in a 1 M potassium borate buffer (KBi, pH 9.5). Before each PEC measurement, Ar gas was purged for at least 10 minutes to remove any dissolved oxygen. A solar simulator using a 300 W Xe lamp (ScienceTech, Inc.) coupled with an AM 1.5G filter at an intensity of 100 mW cm<sup>-2</sup> was used as light source for all PEC measurements. The photocurrent density *vs.* applied potential curves was obtained using linear sweep voltammetry with a scan rate of 20 mV s<sup>-1</sup>. Electrochemical impedance spectroscopy (EIS) was performed with frequencies ranging from 0.1 Hz to 100 kHz at different voltages under constant illumination. The applied bias photon-to-current efficiency (ABPE) is calculated using the following equation:

$$ABPE(\%) = j \times \frac{1.23 - V_b}{P_{\text{light}}} \times 100\%, \quad (1)$$

where  $j$  refers to the photocurrent density (mA cm<sup>-2</sup>) obtained from the Autolab workstation,  $V_b$  represents the applied bias *versus* RHE (V), and  $P_{\text{light}}$  is the total light intensity of AM 1.5G (100 mW cm<sup>-2</sup>). Mott-Schottky (MS) measurements were performed at 1 kHz under dark condition with a suitable range of

potentials to determine flat-band potentials and dopant density of the photoanodes. The MS equation for n-type and p-type semiconductors is given as follows:<sup>26</sup>

$$\frac{1}{C_{\text{SC}}^2} = \frac{2}{eA^2\epsilon_r\epsilon_0N_D} \left( E - E_{\text{fb}} - \frac{kT}{e} \right), \text{ n-type} \quad (2)$$

$$\frac{1}{C_{\text{SC}}^2} = \frac{2}{eA^2\epsilon_r\epsilon_0N_A} \left( -E + E_{\text{fb}} - \frac{kT}{e} \right), \text{ p-type}$$

where  $C_{\text{SC}}$  is the total capacitance in the space-charge depletion layer,  $\epsilon_0$  is the permittivity in the vacuum,  $\epsilon_r$  is the relative permittivity of the semiconductor ( $\epsilon_r = 68, 13,$  and  $18$  for BVO,<sup>27</sup> FeNiO<sub>x</sub><sup>28</sup> and FeMnO<sub>x</sub><sup>29</sup> semiconductors, respectively),  $A$  is the surface area of the working electrode,  $E$  is the applied potential,  $E_{\text{fb}}$  is the flat-band potential,  $N_D$  is the donor carrier density,  $N_A$  is the acceptor carrier density, and  $T$  is the temperature. The majority carrier densities are calculated from the slopes, whereas  $E_{\text{fb}}$  is determined from the  $x$ -intercept of the  $C_{\text{SC}}^{-2}$  *versus*  $E$ .

The incident photon-to-current conversion efficiency (IPCE) was obtained using a Bausch&Lomb 1350 grooves/mm monochromator coupled with a 300 W Cermax Xe lamp as the simulated light source. In addition, an applied potential of 1.23 V *vs.* RHE was supplied by an Autolab workstation, and the power density at a specific wavelength was measured by a photometer Gentec XLP 12-3S-H2-D0. The IPCE values are calculated from equation (3), where  $j$  is the photocurrent density (mA cm<sup>-2</sup>),  $\lambda$  refers to the incident light wavelength (nm), and  $P_{\text{light}}$  is the power density obtained at a specific wavelength (mW cm<sup>-2</sup>).

$$IPCE(\%) = \frac{j \times 1240}{\lambda \times P_{\text{light}}} \times 100\%, \quad (3)$$

The estimated values of charge separation ( $\eta_{\text{sep}}(\%)$ ) and charge transfer ( $\eta_{\text{cat}}(\%)$ ) yields were calculated from the methodology proposed by Dotan. *et al.*<sup>30</sup> In particular, the photocurrent densities observed in PEC measurements result from three distinct processes: (i) light absorption, (ii) separation and transport of photogenerated charges, and (iii) injection of photogenerated charges into the electrolyte. Therefore, the photocurrent density can be expressed by  $j = j_{\text{abs}} \times \eta_{\text{sep}} \times \eta_{\text{inj}}$  where  $j$  (mA cm<sup>-2</sup>) is the current density observed in PEC measurements,  $j_{\text{abs}}$  is the absorption current density defined as the photocurrent obtained when all absorbed photons are converted to electric current,  $\eta_{\text{sep}}$  is the electron-hole separation yield, and  $\eta_{\text{cat}}$  the charge carrier injection yield. The absorption current density ( $j_{\text{abs}}$ ) was calculated using the following equation:<sup>3</sup>

$$j_{\text{abs}} = \int_{300}^{600} \frac{\lambda(\text{nm})}{1240(\text{V nm})} \phi(\lambda) \left( 1 - 10^{-A(\lambda)} \right) \left( \frac{\text{mW}}{\text{cm nm}} \right) d\lambda, \quad (4)$$

where  $\phi(\lambda)$  is the AM 1.5G photon flux in units of Wm<sup>-2</sup> nm<sup>-1</sup> (provided by the National Renewable Energy Laboratory, USA), and  $A(\lambda)$  is the absorbance at different wavelengths estimated by UV-vis measurements.



## Results and discussion

### Synthesis, structural and optical properties of bare BVO and $\text{FeMO}_x$ ( $M = \text{Co}, \text{Ni}$ and $\text{Mn}$ ) films

RF-magnetron sputtering was employed to deposit BVO film from a homemade ceramic target. The thickness and annealing temperature parameters were varied to improve the crystallization and PEC performance of the as-prepared  $\text{BiVO}_4$  (BVO) films. Briefly, the film deposited for 8 minutes and calcined at  $400^\circ\text{C}$  for 1 hour crystallizes in the desired BVO phase and has the highest PEC performance. Therefore, this optimized BVO film was employed for further characterizations and subsequent cocatalyst deposition. Fig. 1A shows the cross-sectional SEM image of bare BVO film after annealing at  $400^\circ\text{C}$  for 1 h. The white shaded region of the SEM image represents the thickness of the FTO substrate, which is about 585 nm. If we closely look at the top of the FTO substrate in the SEM image, there is a thin layer of the BVO of  $\sim 80$  nm, which is consistent with its deposition rate of  $10.06 \text{ nm min}^{-1}$  (measured by profilometry). In addition, Fig. 1B exhibits the top-view SEM image of the bare BVO film, showing the presence of compact and uniform particles ranging from 30 to 50 nm, densely covering the surface of the FTO substrate, as expected from an RF-magnetron sputtering deposition.

The crystalline structure of the bare BVO film was characterized using a combination of XRD and Raman spectroscopy. According to Fig. 1C, the prominent diffraction peaks observed in the XRD pattern corresponds to the monoclinic-scheelite (m-s) structure of  $\text{BiVO}_4$  (JCPDS Card No. 14-0688). The other additional peaks (represented with star sign) are all characteristic of the FTO substrate. Fig. 1D shows the Raman spectra of

the bare BVO film, clearly evidencing five vibrational bands at about  $\sim 210, 327, 367, 702,$  and  $826 \text{ cm}^{-1}$ , which are typical signatures of monoclinic  $\text{BiVO}_4$ . The more intense band at around  $826 \text{ cm}^{-1}$  corresponds to the symmetrical stretching mode of the V–O bonds, whereas the shoulder peak at  $712 \text{ cm}^{-1}$  is attributed to their asymmetric stretching modes. The vibration bands at  $\sim 327$  and  $367 \text{ cm}^{-1}$  are associated with asymmetric and symmetrical deformation modes of the  $\text{VO}_4^{3-}$  tetrahedron, respectively. Finally, the band at  $\sim 210 \text{ cm}^{-1}$  is attributed to the external modes, corresponding to the translations and vibrations of the molecular entities within the crystal-line structure.<sup>31,32</sup>

Diffuse UV-vis spectroscopy measurements were performed to investigate the optical properties of bare BVO film. Fig. 1E shows its absorption spectra, revealing a band edge absorption of  $\sim 485 \text{ nm}$ , which is typical of monoclinic  $\text{BiVO}_4$  with a bandgap energy of 2.4–2.6 eV. Remarkably, a broad and intense absorption tail is observed for wavelengths higher than 500 nm, indicating structural defects in the BVO film (confirmed by XPS analysis, as discussed below), which thereby result in localized states within the bandgap region.<sup>33</sup> Furthermore, Tauc analysis of bare BVO film (inset of Fig. 1E) indicates a direct bandgap energy (considered due to the sharp increase in absorbance for lower wavelengths after the absorption onset) of about 2.60 eV, which is consistent with previous research.<sup>8,19,34</sup>

To suppress charge recombination and accelerate chemical reaction kinetics, we used the appropriate metal-alloy targets to deposit  $\text{FeMO}_x$  ( $M = \text{Ni}, \text{Mn}$ ) cocatalysts on the surface of BVO films. As shown in Fig. S2 (ESI<sup>†</sup>), Fe–Ni and Fe–Mn deposition for 60 seconds yield BVO/ $\text{FeMO}_x$  heterojunctions with higher PEC performance. However, characterizing these

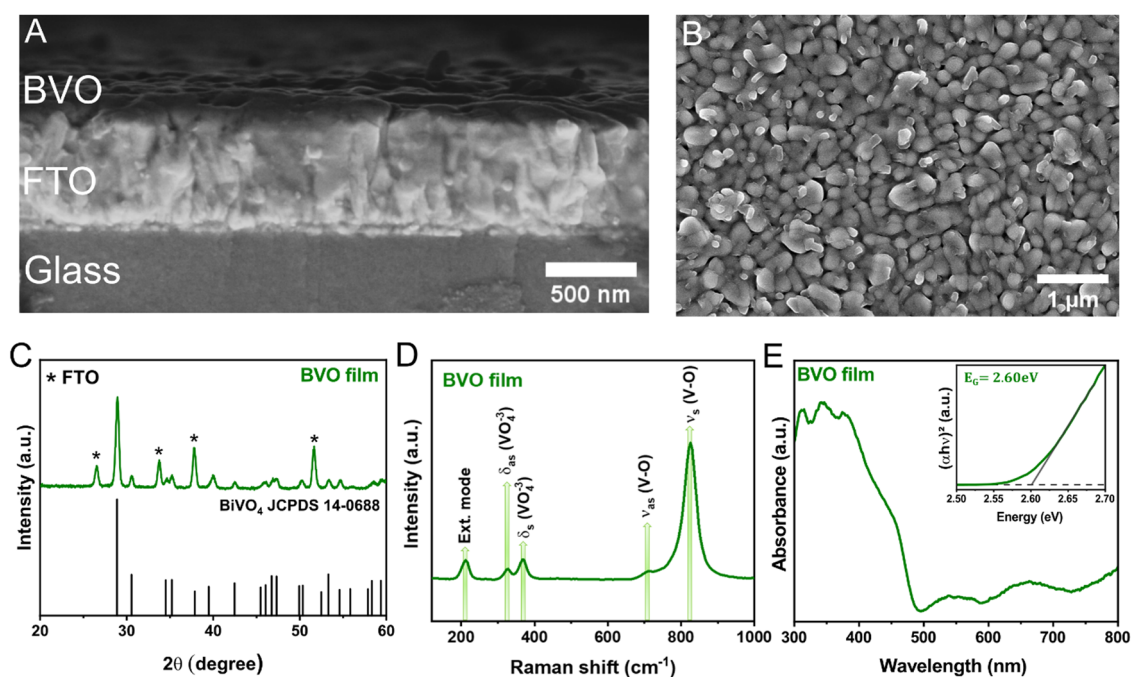


Fig. 1 Characterization of bare BVO film deposited for 8 minutes and calcined at  $400^\circ$  for 1 hour: (A) cross-section SEM images, (B) Top view SEM images, (C) XRD patterns, (D) Raman spectrum and (E) UV-vis absorption spectrum, inset: Tauc Plot analysis.



heterostructured films becomes challenging due to the ultra-thin thickness of the as-deposited  $\text{FeMO}_x$  layers. Profilometry measurements estimated the thickness of  $\text{FeMnO}_x$  and  $\text{FeNiO}_x$  films to be 0.94 and 1.37 nm, respectively. In particular, there was no noticeable change in the XRD pattern or Raman spectrum of bare BVO after surface modification with  $\text{FeNiO}_x$  and  $\text{FeMnO}_x$  bimetallic oxides. As shown in Section 3.2, only XPS analysis can unambiguously confirm the presence of these cocatalysts on the surface of BVO films. Furthermore, determining the (photo)electrochemical properties of  $\text{FeMO}_x$  layers is difficult for the same reasons mentioned above. As a result, we deposited  $\text{FeMO}_x$  films on the FTO substrate with one hour of MSD (maintaining the other parameters) to extract their essential kinetic parameters (overpotentials) and band energy diagrams. The detailed deposition parameters, XRD patterns and Tauc plots of as-prepared  $\text{FeMO}_x$  films are discussed in the ESI† (Fig. S3).

### Electronic properties of bare BVO and BVO/ $\text{FeMO}_x$ (M = Ni, Mn) films

X-ray photoelectron spectroscopy (XPS) was performed on the bare BVO and BVO/ $\text{FeMO}_x$  (M = Ni, Mn) films to provide a comprehensive understanding of their electronic structure and surface chemical composition. Fig. 2A and B show the XPS spectra for bare BVO after annealing at 400 °C for 1 h. Highly resolved Bi 4f core-level spectra revealed two distinct peaks, with the Bi 4f<sub>5/2</sub> peak at 164.2 eV and the Bi 4f<sub>7/2</sub> peak at 158.9 eV. Both of these peaks are assigned to Bi<sup>3+</sup> in the electronic structure of BiVO<sub>4</sub>, respectively.<sup>35</sup> The high-resolution

XPS spectra of the V 2p region display one spin-orbit doublet located at 516.6 eV and 524.3 eV, respectively. The spin-orbit split of 7.7 eV, which separates the V 2p<sub>3/2</sub> and V 2p<sub>1/2</sub> peaks, is typical for the V<sup>5+</sup> oxidation state in the BiVO<sub>4</sub> electronic structure. Nonetheless, the peak areas of the spin orbit split do not match the 2:1 ratio predicted for the 2p orbital. Furthermore, the line shape is asymmetric for a Gaussian/Lorentzian function, which might indicate the presence of another oxidation state, such as V<sup>4+</sup>, which could result in the formation of an oxygen defect/vacancy. In addition, the full width at half maximum (FWHM) for the V 2p<sub>1/2</sub> peak is broadened than to the V 2p<sub>3/2</sub>, where the ratio of FWHM for these two peaks was 1.62 eV, attributable to the Coster-Kronig effect, where distinguishing V<sup>5+</sup> and V<sup>4+</sup> species by XPS is a challenging operation to identify them precisely.<sup>36,37</sup>

Furthermore, Fig. S4 (ESI†) shows that the O 1s XPS spectra for the bare BVO film can be fitted into three distinct peaks. The peak observed at 529.5 eV corresponded to oxygen lattice in BiVO<sub>4</sub>, while the peak at 531.3 eV is commonly attributed to signals from oxygen defects in a semiconductor structure, associated with oxygen vacancies, and the less intense peak observed at 532.7 eV is associated with C-O groups.<sup>8,38</sup> The presence of oxygen vacancy/defects (O<sub>vo</sub>) can significantly modify the electronic structure of BiVO<sub>4</sub> and, hence photoelectrochemical characteristics of the compound. Several studies have proposed that the oxygen vacancies may induce charge transition levels within the bandgap (intragap), resulting in a reduction in the recombination site and an increase in *n*-type conductivity, which are responsible for the increased photocatalytic activity of BiVO<sub>4</sub>.<sup>39</sup> As previously noted, the existence

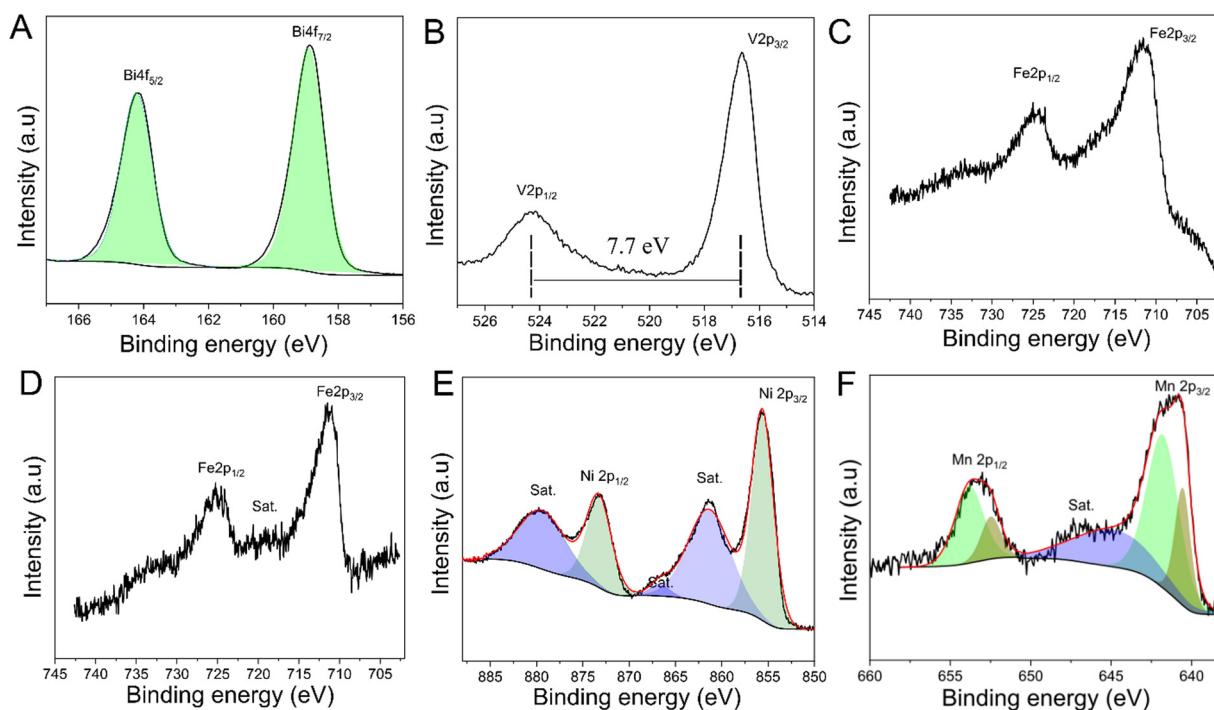


Fig. 2 XPS spectra of bare BiVO<sub>4</sub> at 400 °C for 1 hour: (A) Bi 4f and (B) V 2p. XPS spectra of as-sputtered  $\text{FeMO}_x$  (M = Ni, Mn) on BVO films: (C) Fe 2p with  $\text{FeNiO}_x$  deposited for 60 s, (D) Fe 2p with  $\text{FeMnO}_x$  deposited for 60 s, (E) Ni 2p with  $\text{FeNiO}_x$  deposited for 60 s, and (F) Mn 2p with  $\text{FeMnO}_x$  deposited for 60 s.



of oxygen vacancies/defects is a significant indicator of  $V^{5+}/V^{4+}$  in the electronic structure of BVO. Beyond oxygen vacancies/defects, adjusting the atomic ratio of Bi/V in the structure of  $\text{BiVO}_4$  through a solution containing vanadium ions has been an essential strategy to improve PEC performance in the water splitting reaction.<sup>39</sup>

XPS was also used to characterize the chemical surface composition of the as-deposited  $\text{FeMO}_x$  ( $M = \text{Ni, Mn}$ ) layers through RF-magnetron sputtering on the surface of BVO films. The Fe 2p XPS spectra of  $\text{FeNiO}_x$  and  $\text{FeMnO}_x$  are shown in Fig. 2C and D. All high-resolution spectra of Fe 2p presented a spin-orbit doublet located close to 711.2 eV and 724.9 eV, which corresponds to the spin-orbital splitting of  $2p_{3/2}$  and  $2p_{1/2}$  of  $\text{Fe}^{3+}$  ions in the  $\text{FeNiO}_x$  and  $\text{FeMnO}_x$  structures.<sup>40,41</sup> The XPS spectra of Ni 2p (Fig. 2E) show two characteristic peaks at 855.6 and 873.2 eV, corresponding to the  $\text{Ni}^{2+}$  oxidation state. In addition, the presence of two more intense satellite peaks around 861.3 and 879.3 eV may also indicate the presence of  $\text{Ni}^{2+}$  in the  $\text{FeNiO}_x$  structure. Finally, the Mn 2p spectra (Fig. 2F) can be deconvoluted into four peaks using an asymmetric Gaussian-Lorentzian function with a ratio G:L (60:40). The peaks at 653.8 and 641.7 eV can be attributed to the  $\text{Mn}^{3+}$  species, while the two other peaks at 652.4 and 640.5 eV correspond to the binding energy of  $\text{Mn}^{2+}$ . It has been noticed that the doublet separation of both  $\text{Mn}^{3+}$  and  $\text{Mn}^{2+}$  species for Mn 2p is 12.1 eV, which is slightly higher than that of the Mn oxide bulk material commonly reported in the literature, which has a spin-orbit separation of between 11.0 and 12.0 eV.<sup>40</sup> As a result of the small size of the  $\text{FeMnO}_x$  cocatalyst that was deposited on the BVO surface by magnetron sputtering, it is possible that there is a strong interaction between Mn-Fe-O atoms and the BVO layer, which could explain the slight displacement.

### Photoelectrochemical properties of bare BVO and BVO/ $\text{FeMO}_x$ ( $M = \text{Ni, Mn}$ ) films

The PEC performance of bare BVO and BVO/ $\text{FeMO}_x$  ( $M = \text{Ni, Mn}$ ) films were evaluated in a 1 M potassium borate buffer (KBi, pH 9.5). Fig. 3A shows the current density vs. applied potential ( $j$ - $V$ ) curves under constant 100  $\text{mW cm}^{-2}$  AM 1.5G illumination. The bare BVO film exhibits an onset potential of around 0.47 V vs. RHE and a photocurrent density of only 0.50  $\text{mA cm}^{-2}$  at the water oxidation potential (+1.23 V vs. RHE). This photocurrent density is comparable to that obtained for bare BVO films deposited *via* MSD,<sup>19,39</sup> but much lower than those obtained from electrodeposition technique.<sup>8,9</sup> Encouragingly, all surface-modified BVO films showed significantly enhanced PEC performance, with the new BVO/ $\text{FeMnO}_x$  photoanode achieving the highest photocurrent density of 1.25  $\text{mA cm}^{-2}$  at +1.23 V vs. RHE. Moreover, upon  $\text{FeMnO}_x$  deposition, the onset potential of bare BVO was cathodic shifted to +0.33 V vs. RHE (corresponding to a  $\approx 140$  mV shift), indicating improved charge separation efficiency in the low applied potential range. Interestingly, the BVO/ $\text{FeNiO}_x$  heterojunction exhibited a similar onset potential at around 0.34 V vs. RHE but a significantly lower photocurrent density of

1.00  $\text{mA cm}^{-2}$  at +1.23 V vs. RHE compared with the BVO/ $\text{FeMnO}_x$  film. To further investigate the enhanced PEC performance of the surface-modified BVO films, the applied bias photon-to-current efficiency (ABPE) curves of the BVO, BVO/ $\text{FeNiO}_x$ , and BVO/ $\text{FeMnO}_x$  films were determined using equation (1). As shown in Fig. 3B, the bare BVO film exhibits an ABPE peak of only 0.04% at around 1.01 V vs. RHE, whereas the ABPE peak of the BVO/ $\text{FeNiO}_x$  reaches a significant increase of 0.26% at a lower potential (0.79 V vs. RHE). In contrast, the  $\text{FeMnO}_x$  cocatalyst further improves the optimal ABPE to 0.39% (at 0.74 V vs. RHE), which is almost tenfold higher than the bare BVO film. These results indicate that surface modification of the BVO top layer with an OER cocatalyst is essential for solving its intrinsic sluggish water oxidation kinetics and surface charge recombination. Crucially, the  $j$ - $V$  and ABPE curves clearly prove that the  $\text{FeMnO}_x$  compound has superior catalytic activity for the PEC water oxidation than the conventional  $\text{FeNiO}_x$  cocatalyst.

It is well-known that the formation of p-n heterojunctions considerably enhances the charge separation due to a built-in electric field, which accelerates photogenerated charges and outperforms the negative effects of electrical resistance and recombination centers at the BVO/p-type layer interface.<sup>11,19,42</sup> As will be shown in Section 3.4, the  $\text{FeNiO}_x$  and  $\text{FeMnO}_x$  layers unambiguously exhibit p-type character. Therefore, to verify the possible development of p-n heterojunctions in our surface-modified BVO films, Mott-Schottky curves of bare BVO, BVO/ $\text{FeNiO}_x$ , and BVO/ $\text{FeMnO}_x$  films were measured at 1 kHz under dark conditions. Fig. 3C indicates that all heterojunctions show a positive shift in the flat band potential compared to bare BVO, evidencing that Fermi energy shifts once the bimetallic oxides contact the BVO surface. Consequently, the Fermi energy of the BVO is shifted to higher energies after contact with  $\text{FeNiO}_x$  and  $\text{FeMnO}_x$  layers, unambiguously demonstrating the development of p-n heterojunctions.<sup>8,19</sup> Remarkably, the electron concentrations ( $N_D$ ) in the bare BVO and BVO/ $\text{FeMO}_x$  ( $M = \text{Ni, Mn}$ ) heterojunctions – determined from the slopes of the straight lines shown in Fig. 3C – are around  $10^{19} \text{ cm}^{-3}$  for all films, indicating that there is no apparent increase in  $N_D$  of bare BVO film after the formation of the p-n heterojunctions, which is most likely due to the ultrathin thickness of the bimetallic oxide layers deposited on the surface of BVO film.

To investigate the influence of light absorption on enhanced PEC performance of the surface-modified BVO films, we measured their incident-photon-to-current (IPCE) values under monochromatic illumination of different wavelengths and subjected to +1.23 V vs. RHE. As shown in Fig. 3D, the BVO/ $\text{FeNiO}_x$  and BVO/ $\text{FeMnO}_x$  photoanodes have higher IPCE values for all measured wavelengths, evidencing the enhanced optical properties upon the deposition of bimetallic oxide cocatalysts on the BVO surface. The bare BVO film, in particular, exhibits an absorption threshold potential close to 495 eV, which is consistent with UV-Vis spectra; additionally, the conversion of photons with energy less than 2.5 eV ( $>495$  nm) into the electrical current is null (IPCE  $\approx 0$ ), indicating that the tail absorption band observed in Fig. 1E plays no direct role in the



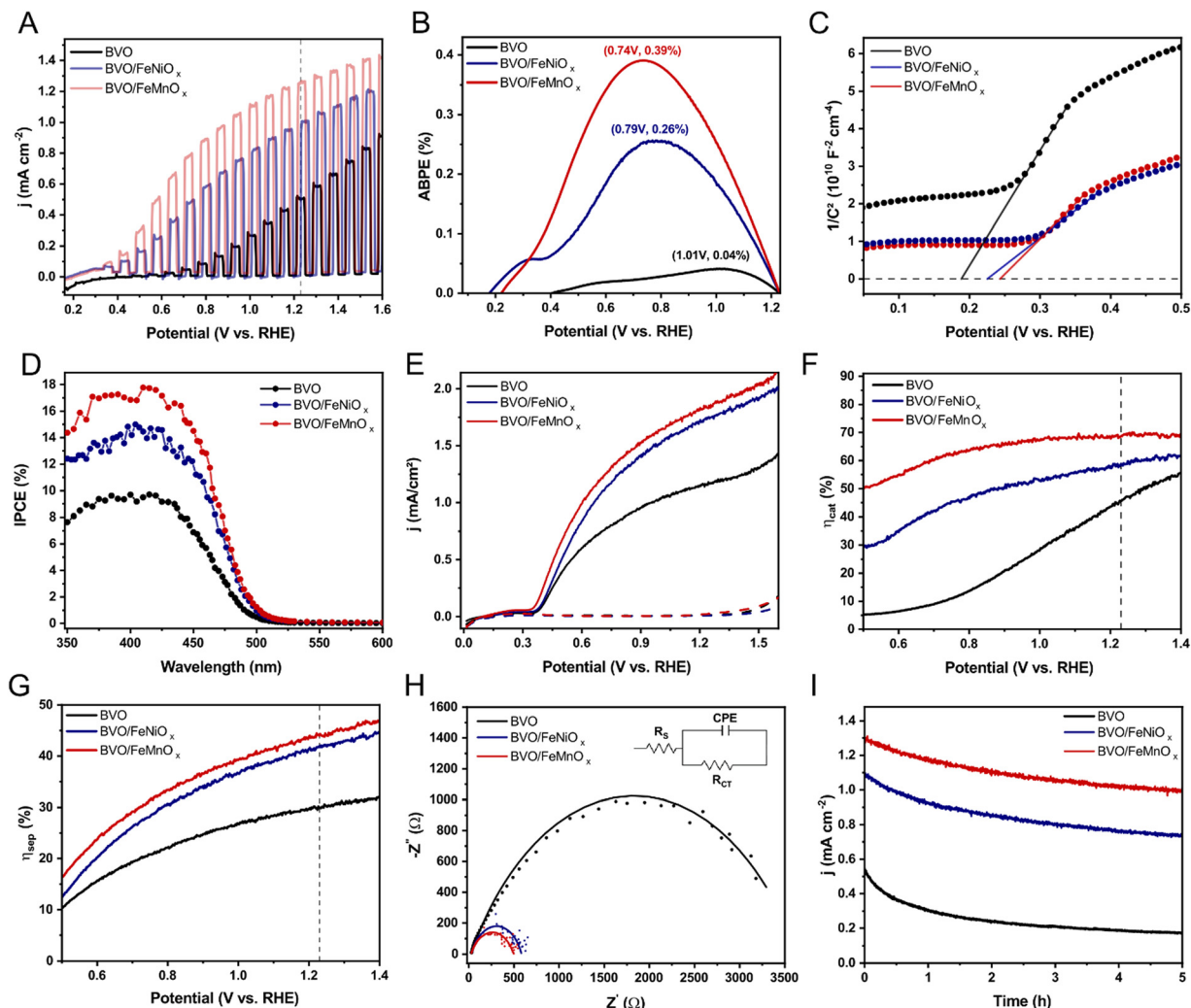


Fig. 3 Photoelectrochemical properties of BVO-based photoanodes: (A) photocurrent density vs. applied potential curves with 1 M KBI (pH 9.5); (B) ABPE curves; (C) Mott–Schottky curves; (D) IPCE curves obtained at +1.23 V vs. RHE; (E) potential curves with 0.25 M  $\text{Na}_2\text{SO}_3$  as a hole scavenger; (F) charge transfer efficiencies and (G) charge separation efficiency at different applied potentials; (H) EIS response measured under +0.90 V vs. RHE and (inset) the equivalent circuit model ( $R_s$ ,  $R_{CT}$  and CPE refers to series resistance, charge transfer resistance and the constant phase element, respectively); (I) temporal stability by chronoamperometry measurements of bare BVO and BVO/ $\text{FeMO}_x$  ( $M = \text{Ni, Mn}$ ) heterojunctions.

PEC performance of bare BVO film. Interestingly, all BVO/ $\text{FeMO}_x$  heterojunctions ( $M = \text{Ni, Mn}$ ) have identical potential absorption thresholds with a red shift compared to bare BVO film (corroborating with UV-Vis analysis, see Fig. S5, ESI<sup>†</sup>), suggesting that a higher number of photons may be efficiently converted to electrical current. Significantly, the IPCE values at 400 nm, as an example, increase to 14.4% for BVO/ $\text{FeNiO}_x$  and 16.9% for BVO/ $\text{FeMnO}_x$  compared to 9.6% for bare BVO film. Similarly, since IPCE values beyond the threshold potential are null, the extended absorption tail bands seen in Fig. S5 (ESI<sup>†</sup>) for all BVO/ $\text{FeMO}_x$  ( $M = \text{Ni, Mn}$ ) heterojunctions cannot be directly converted to photocurrent densities.

To unravel the charge-separation effect across the BVO/ $\text{FeMO}_x$  ( $M = \text{Ni, Mn}$ ) p–n heterojunctions, the photocurrent density ( $j$ ) from the PEC measurements was decoupled into three significant contributions:  $j = j_{\text{abs}} \times \eta_{\text{cat}} \times \eta_{\text{sep}}$ , as detailed in the experimental section.<sup>30</sup> The values of  $j_{\text{abs}}$  for bare BVO,

BVO/ $\text{FeNiO}_x$ , and BVO/ $\text{FeMnO}_x$  heterojunctions, calculated from equation (4), are 3.86, 4.15, and 4.17  $\text{mA cm}^{-2}$ , respectively (Fig. S6, ESI<sup>†</sup>). To assess the charge separation ( $\eta_{\text{sep}}$ ) and interfacial transfer efficiencies ( $\eta_{\text{cat}}$ ), we performed the PEC measurements with 1 M KBI in the presence of 0.25 M  $\text{Na}_2\text{SO}_3$ . As shown in Fig. 3E, the  $\text{Na}_2\text{SO}_3$  species exhibits fast kinetics for consuming photogenerated holes at the semiconductor-electrolyte interface ( $\eta_{\text{cat}} \sim 1$  and  $\eta_{\text{sep}} \approx j/j_{\text{abs}}$ ), resulting in higher photocurrent density values. Fig. 3F and G show the calculated efficiencies as a function of the applied potential. For the bare BVO photoanode, both  $\eta_{\text{cat}}$  and  $\eta_{\text{sep}}$  rise from small values under low applied potentials to  $\sim 45.0$  and  $\sim 29.9\%$ , respectively, at +1.23 V vs. RHE. As a result, the charge separation effect is the key-limiting factor during the PEC water oxidation with BVO films, indicating that surface modification techniques are essential. Conclusively, the BVO/ $\text{FeMnO}_x$  photoanode significantly enhances the charge separation efficiency



under low applied bias, reaching  $\sim 44.3\%$  at  $+1.23$  V *vs.* RHE. Moreover, the catalytic efficiency was also dramatically improved, reaching  $68.7\%$  at  $+1.23$  V *vs.* RHE. Interestingly, the BVO/FeNiO<sub>x</sub> exhibits a similar charge separation efficiency of  $\sim 41.8\%$  at  $+1.23$  V *vs.* RHE compared with the BVO/FeMnO<sub>x</sub>, but a significantly lower catalytic efficiency of  $58.8\%$  at the same potential. These significant results indicate that the FeMnO<sub>x</sub> has superior activity (compared to conventional FeNiO<sub>x</sub>) for separating photogenerated charges (due to the presence of a more intense built-in electric field, as will be discussed in Section 3.4) and consuming the photogenerated holes from the BVO layer, thereby reducing the onset potential for water oxidation and enhancing the PEC performance, which is consistent with Fig. 3A.

To further investigate the interfacial charge transfer kinetics at the photoanode/electrolyte interfaces, we performed electrochemical impedance spectroscopy (EIS) curves of BVO, BVO/FeNiO<sub>x</sub>, and BVO/FeMnO<sub>x</sub> photoanodes at  $+0.90$  V *vs.* RHE under constant  $100$  mW cm<sup>-2</sup> AM 1.5G illumination. As shown in Fig. 3H, the Nyquist plots of bare BVO and BVO/FeMO<sub>x</sub> (M = Ni, Mn) heterojunctions exhibit only a single semicircle, which can be simulated from the equivalent circuit shown in the onset, characterized by a series resistance ( $R_s$ ) through the material, charge transfer resistance ( $R_{ct}$ ) at the photoanode/electrolyte interface and a constant phase element (CPE) to describe the double-layer capacitance across the inhomogeneous electrode surface.<sup>43</sup> The diameters of the Nyquist semicircles give information about  $R_{ct}$ , thereby providing a direct comparison between electron transfer kinetics at the photoanode/electrolyte interface for different films. According to Table S1 (ESI<sup>†</sup>), the calculated  $R_{ct}$  values for BVO/FeMO<sub>x</sub> (M = Ni, Mn) heterostructures are significantly lower than that of bare BVO, clearly indicating that the synergetic effect of heterojunction formation and cocatalyst effect may improve interfacial charge separation and increase the overall PEC performance. Interestingly, the new BVO/FeMnO<sub>x</sub> film exhibited the lowest  $R_{ct}$  value, indicating that the FeMnO<sub>x</sub> layer has superior cocatalyst activity compared with conventional FeNiO<sub>x</sub>, corroborating the higher  $\eta_{cat}$  efficiency and photocurrent density values.

The PEC stability of bare BVO, BVO/FeNiO<sub>x</sub>, and BVO/FeMnO<sub>x</sub> photoanodes were evaluated through chronoamperometry measurements ( $j-t$  curves). Fig. 3I shows the  $j-t$  curves for the BVO-based photoanodes submitted to  $1.23$  V *vs.* RHE and under AM 1.5G illumination for 5 hours. The bare BVO film, in particular, exhibits severe instability in the  $1$  M KBI buffer at pH 9.5, retaining only  $31.7\%$  of its initial value during 5 hours. The chemical instability of BVO photoanodes in the presence of potassium borate species at pH 9.5 is probably attributed to significant photo corrosion of the BVO layer during the PEC measurement. In contrast, the BVO/FeNiO<sub>x</sub> and BVO/FeMnO<sub>x</sub> films exhibit superior PEC stability, retaining  $\sim 67.7\%$  and  $\sim 77.2\%$  of their initial photocurrent density during 5 hours, respectively. These significant results indicate that the deposition of Fe-based bimetallic oxides also protects the BVO layer from photocorrosion, consistent with previous

research concerning BVO/FeCoO<sub>x</sub> heterojunctions.<sup>8,19</sup> To further compare the effect of the different bimetallic oxides for improving the PEC performance of the BVO film, we determined the electrochemical kinetic parameters and energy band alignment (discussed in Section 3.4) of the bare FeNiO<sub>x</sub> and FeMnO<sub>x</sub> films. Importantly, these films were deposited on FTO substrates using one hour of MSD, keeping the other parameters for preparing the BVO/FeMO<sub>x</sub> (M = Ni, Mn) photoanodes. Current density *versus* applied potential ( $j-V$ ) curves was measured under dark conditions to access the overpotential of FeMO<sub>x</sub> (M = Ni, Mn) films. As shown in Fig. S7 (ESI<sup>†</sup>), the FeMnO<sub>x</sub> film exhibits a smaller overpotential to reach  $10$  mA cm<sup>-2</sup> ( $\eta = 875$  mV) compared to FeNiO<sub>x</sub> ( $\eta = 922$  mV) and a steeper water oxidation current density, resulting in a higher surface water oxidation kinetics and clearly justifying the superior OER catalytic performance of the FeMnO<sub>x</sub> compound compared to conventional FeNiO<sub>x</sub>.

### Interfacial band alignment of BVO/FeMO<sub>x</sub> (M = Ni, Mn) heterojunctions

To provide solid insights into the interfacial band alignment and charge transfer process in the BVO-based heterojunctions, we begin by constructing the semiconductor band diagrams from UV-Vis spectroscopy, valence band (VB) XPS spectra, and Mott-Schottky analysis. Fig. 4A shows the VB XPS spectra of bare BVO and bare FeMO<sub>x</sub> (M = Ni, Mn) films, indicating the distance between the Fermi energy ( $E_F$ ) and the VB maximum ( $E_V$ ) as the intersection of the baseline intensity and the linear extrapolation of the leading edge of VB.<sup>19,44,45</sup> The BVO film has a VB maximum located  $1.72$  eV below the Fermi level, indicating its n-type nature. In contrast, the bimetallic oxide films exhibit a VB edge with only  $0.60$  and  $0.68$  eV below  $E_F$  for FeNiO<sub>x</sub> and FeMnO<sub>x</sub> films, respectively, evidencing their p-type nature. Furthermore, Mott-Schottky curves of the bare BVO and bare FeMO<sub>x</sub> (M = Ni, Mn) films were performed at  $1$  kHz under the dark condition to estimate their Fermi energy position and dopant concentrations. As shown in Fig. 4B, the BVO film exhibits a straight line with a positive slope, characteristic of n-type semiconductors, resulting in a flat band potential ( $E_{FB}$ ) of  $0.19$  V *vs.* RHE and an electron concentration ( $N_D$ ) of  $6.6 \times 10^{18}$  cm<sup>-3</sup>. Conversely, all bimetallic oxides show a straight line with a negative slope, confirming their p-type nature. The FeNiO<sub>x</sub> has a flat band potential at around  $0.96$  V *vs.* RHE and acceptor concentration ( $N_A$ ) of  $3.6 \times 10^{21}$  cm<sup>-3</sup>, whereas the FeMnO<sub>x</sub> film exhibits a flat band potential at  $1.13$  V *vs.* RHE and a high acceptor concentration of  $3.3 \times 10^{22}$  cm<sup>-3</sup>. The band diagrams sketched in Fig. 4C are derived by assuming  $E_{FB} \approx E_F$  (considering isolated semiconductors) and combining the VB measured by XPS, Mott-Schottky analysis, and bandgap energies obtained from the UV-Vis spectroscopy (Fig. 1E and Fig. S3, ESI<sup>†</sup>), as reported elsewhere.<sup>19,46</sup>

According to the traditional band alignment based on flat band diagrams, the BVO/FeMnO<sub>x</sub> heterojunction exhibits a typical type I alignment (see Fig. S8, ESI<sup>†</sup>), where photogenerated holes in the VB of the BVO layer tend to migrate towards the VB of FeMnO<sub>x</sub> cocatalyst, and photogenerated electrons in the CB of BVO tend to flow into the CB of FeMnO<sub>x</sub>. However,



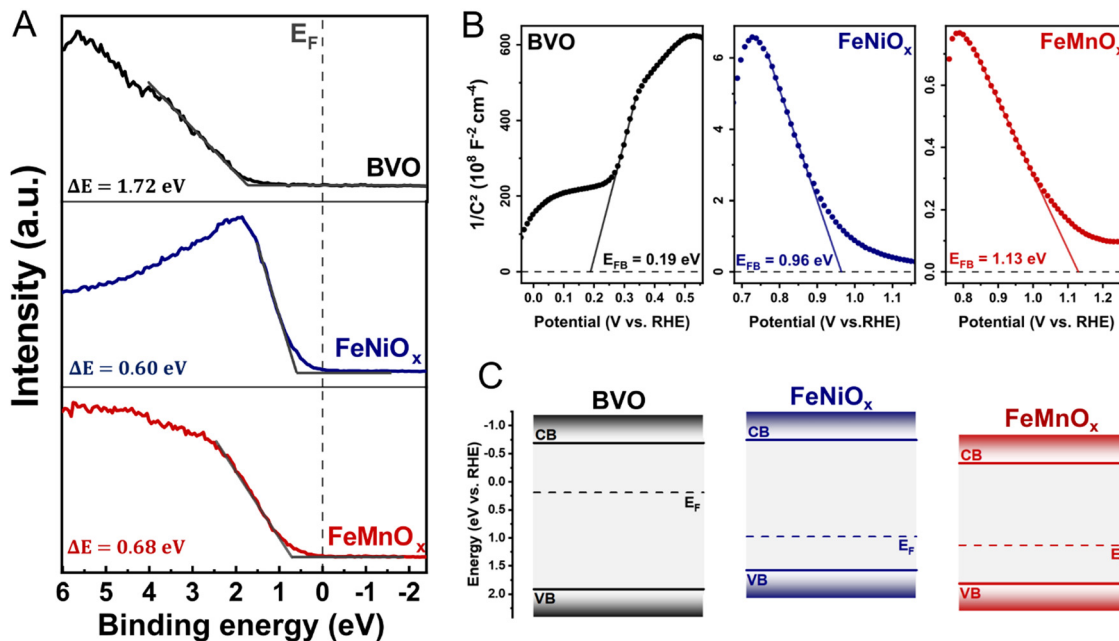


Fig. 4 (A) valence band XPS spectra for bare BVO and bare FeMO<sub>x</sub> films; (B) Mott Schottky plot for bare BVO and bare FeMO<sub>x</sub> films; (C) band diagrams for isolated BVO and FeMO<sub>x</sub> semiconductors. (M = Ni, Mn). In Fig. 4A, ΔE indicates the distance between the valence band edge (E<sub>V</sub>) and Fermi level energy: ΔE = E<sub>V</sub> - E<sub>F</sub>.

the photogenerated electrons in the BVO layer must travel to the FTO substrate to conduct the reduction reactions. Therefore, the electron transfer from BVO to the FeMnO<sub>x</sub> side potentially limits the PEC performance of the BVO/FeMnO<sub>x</sub> heterojunction, which clearly contradicts the results of Section 3.3. Similarly, although the BVO/FeNiO<sub>x</sub> heterojunction presents a typical type II alignment, there is no obvious mechanism that prevents the transfer of electrons from FeNiO<sub>x</sub> to the BVO layer due to its staggered conduction bands (at room temperature,  $kT/e \approx 26$  meV, the electrons may eventually tunnel through the potential barrier  $\Delta E_C = 60$  meV). In conclusion, the absence of type II heterojunctions with high values of conduction band offsets ( $\Delta E_C$ ) suggests the existence of p-n heterojunctions with limited PEC performance because they lack adequate potential barriers to prevent the flow of photo-generated electrons from BVO to FeMO<sub>x</sub> layer. However, as pointed out recently in several publications,<sup>19–21</sup> the interfacial alignment using flat band diagrams may lead to misleading interpretations because it ignores the physical effects that occur at the interface during the heterojunction formation, as discussed below.

From the classical band theory, immediately after contact, there is a preferential flow of electrons from FeMO<sub>x</sub> (semiconductor with higher  $E_F$ ) to BVO (with lower  $E_F$ ) layer to produce a constant Fermi level throughout the entire material (representing a net zero current flow through the p-n heterojunction).<sup>18–20</sup> Consequently, (i) the FeMO<sub>x</sub> valence and conduction bands tend to increase in energy along with its Fermi level, while the valence and conduction bands of the BVO tend to decrease following its Fermi level, and (ii) the band bending effect occurs at the interface between the

semiconductors, which is characterized by the development of a built-in electric field that can mediate the separation and transfer of photoinduced charges. Fig. 5A and B depict the interfacial band alignment of the BVO/FeMO<sub>x</sub> (M = Ni, Mn) heterojunctions constructed from the classical band bending model (details are available in ESI†) under equilibrium conditions, clearly capturing the consequences (i) and (ii) mentioned above. From this result, each p-n interface has a distinct space charge region (SCR) that is defined by the energy drops  $\Psi_n$  and  $\Psi_p$  supported in the n and p layers, respectively, the depletion lengths  $W_n$  and  $W_p$  in the corresponding layers (whose values are shown in Table 1), and the built-in electric field that points from the n to the p side. Importantly, this built-in electric field accelerates the photogenerated electrons in the CB of the BVO layer to the FTO substrate, providing a mechanism that tends to inhibit the flow of electrons to the FeMO<sub>x</sub> layer. Interestingly, both BVO/FeNiO<sub>x</sub> and FeMnO<sub>x</sub> heterojunctions have a space charge region entirely concentrated on the BVO side, resulting from the higher impurity concentration values in the bimetallic oxides ( $N_A \gg N_D$ ). Furthermore, Table 1 shows that the BVO/FeMnO<sub>x</sub> heterojunction display a larger SCR both in spatial ( $W_n$ ) and energetic extent ( $\Psi_n$ ) compared to BVO/FeNiO<sub>x</sub>, suggesting the formation of a more intense built-in electric field that may effectively decrease the onset potential and increase the photocurrent density, which is consistent with the PEC measurements.

The classical analysis of band bending is performed with a band diagram under the equilibrium condition, without applied light and external bias. It is well-known that the band flattening effect occurs upon AM 1.5G illumination and forward external bias. This effect is characterized by: (i) a reduction in



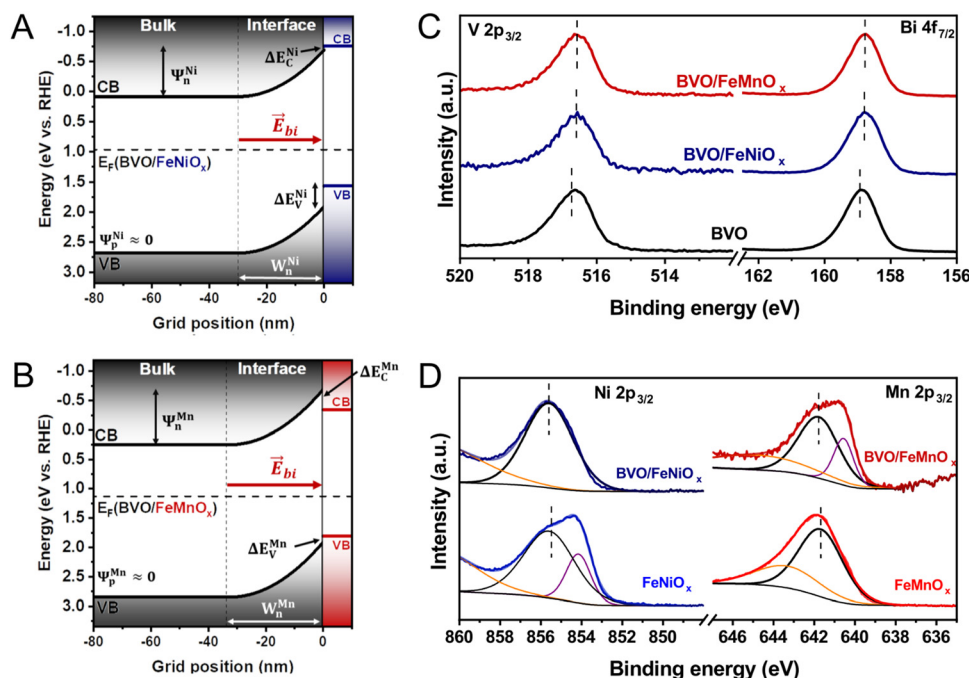


Fig. 5 Interfacial band alignment obtained from the classical band model under dark conditions for (A) BVO/FeNiO<sub>x</sub> and (B) BVO/FeMnO<sub>x</sub> films. High-resolution XPS (C) V 2p<sub>3/2</sub> and Bi 4f<sub>7/2</sub> spectra for bare BVO and BVO/FeMO<sub>x</sub> (M = Ni, Mn) heterojunctions, and high-resolution XPS (D) M 2p<sub>3/2</sub> (M = Ni, Mn) for bare FeMO<sub>x</sub> films and the corresponding BVO/FeMO<sub>x</sub> heterojunctions.

Table 1 Energy drops, depletion lengths, and Fermi energies of BVO/FeMO<sub>x</sub> heterojunctions calculated from classical band bending model

Heterojunction	$\psi_n$ (meV)	$\psi_p$ (meV)	$W_n$ (nm)	$W_p$ (nm)	$E_F$ (eV)
BiVO <sub>4</sub> /FeNiO <sub>x</sub>	772	7.44	29.65	0.05	0.96
BiVO <sub>4</sub> /FeMnO <sub>x</sub>	940	0.72	32.70	0.01	1.13

Table 2 Binding energies of the core levels Ni 2p<sub>3/2</sub>, Bi 4f<sub>7/2</sub> and V 2p<sub>3/2</sub> for the bare BVO and BVO/FeMO<sub>x</sub> films (M = Ni, Mn) and valence band maximum ( $E_V$ ). All energies are given in eV

Film	$E(\text{Co } 2p)$	$E(\text{Ni } 2p)$	$E(\text{Mn } 2p)$	$E(\text{Bi } 4f)$	$E(\text{V } 2p)$	$E_V$	$\Delta E_V$	$\Delta E_C$
BiVO <sub>4</sub>				158.92	516.72	1.72		
FeNiO <sub>x</sub>		855.59				0.60		
FeMnO <sub>x</sub>			641.67			0.68		
BVO/FeNiO <sub>x</sub>		855.60		158.81	516.61	1.00	0.72	
BVO/FeMnO <sub>x</sub>			641.78	158.79	516.58	0.80	0.35	

the spatial and energetic extension of SCR, resulting in a decrease of built-in electric field intensity, and (ii) the splitting of constant Fermi levels into quasi-Fermi levels for holes and electrons.<sup>20</sup> As a result, the built-in electric field considerably weakens during PEC measurements, potentially allowing photogenerated electrons in the CB of the BVO to migrate into the FeMO<sub>x</sub> layer (see Fig. S9, ESI†). Therefore, these results (contradicting the PEC measurements) suggest that the electron affinity law, used as a hypothesis in the band bending model, is not respected in the BVO/FeMO<sub>x</sub> heterojunctions.<sup>18</sup> To solve this problem, we employed Kraut's method to directly determine the interfacial band alignment of our p-n heterojunctions from the XPS technique.

Kraut's method, in particular, directly determines the VB offsets ( $\Delta E_V$ ) from the relative displacement of the binding energies (BE) of some core levels (and the values of the VB maximum) between the individual semiconductor films and the corresponding heterojunctions.<sup>23</sup> To apply this method, we investigated the XPS core-level spectra of bare BVO, bare FeMO<sub>x</sub> (M = Ni, Mn), and the heterostructured films (BVO/FeNiO<sub>x</sub> and BVO/FeMnO<sub>x</sub>). Fig. 5C displays the XPS high-resolution spectra of Bi 4f<sub>7/2</sub> for the BVO film and the BVO/FeMO<sub>x</sub>

heterojunctions. This result shows that the deposition of bimetallic oxides causes a relative decrease in the BE of Bi 4f<sub>7/2</sub> core levels, which is a characteristic signature of the upward band bending effect, as expected when forming the p-n heterojunction.<sup>24,47</sup> Fig. 5D shows the high-resolution XPS spectra for Ni 2p<sub>3/2</sub> and Mn 2p<sub>3/2</sub> for the bare FeMO<sub>x</sub> films and the subsequent BVO/FeMO<sub>x</sub> heterojunctions. As indicated in Fig. S11 (ESI†) and Table 2, the predominant peak center (referring to Ni<sup>2+</sup> for BVO/FeNiO<sub>x</sub> and Mn<sup>3+</sup> for BVO/FeMnO<sub>x</sub>) was considered as the core-level peak position. Importantly, the peak at 642 eV in the BVO/FeMnO<sub>x</sub> heterojunction and the lack of the peak centered at 854 eV for the bare FeNiO<sub>x</sub> film are likely the results of the strong interaction between the bimetallic oxide atoms and the BVO layer. Crucially, the slight shifts of the core-level peak position of FeNiO<sub>x</sub> and FeMnO<sub>x</sub> to the higher BE (compared to the heterostructured films) are directly related to the downward band bending on the p-side of the heterojunction, also indicating the



formation of a p-n heterojunction.<sup>48</sup> Based on these core-level peak shifts, the VB offset can be calculated from Kraut's equation:

$$\Delta E_V = (E_{M2p} - E_{VBM})_{FeMO_x} - (E_{Bi4f} - E_{VBM})_{BVO} + (E_{Bi4f} - E_{M2p})_{BVO/FeMO_x}, \quad (5)$$

where  $(E_{M2p} - E_{VBM})_{FeMO_x}$  and  $(E_{Bi4f} - E_{VBM})_{BVO}$  are differences of BE between core-level positions and the corresponding VB maximum of bare BVO and  $FeMO_x$  ( $M = Ni, Mn$ ) films, respectively.  $(E_{Bi4f} - E_{M2p})_{BVO/FeMO_x}$  is the difference of BE between Bi  $4f_{7/2}$  and  $M_{2p}$  ( $M = Ni, Mn$ ) core levels for BVO/ $FeMO_x$  heterojunctions. Similarly, the conduction band offset ( $\Delta E_C$ ) can be indirectly calculated as  $\Delta E_C = \Delta E_V + (E_G^{BVO} - E_G^{FeMO_x})$ , where  $E_G^{BVO}$  and  $E_G^{FeMO_x}$  are the bandgap energies of BVO and  $FeMO_x$  bare films. Table 2 exhibits the  $\Delta E_V$  and  $\Delta E_C$  values for the BVO/ $FeMO_x$  films calculated from the equations above.

Fig. 6A and B shows the interfacial band alignment of the BVO/ $FeMO_x$  ( $M = Ni, Mn$ ) heterojunctions under dark conditions, considering the  $\Delta E_C$  and  $\Delta E_V$  values calculated by the Kraut's method and the energy drops ( $\Psi_n$  and  $\Psi_p$ ) and depletion lengths ( $W_n$  and  $W_p$ ) determined from classic band bending model. Since the values of  $\Delta E_V$  and  $\Delta E_C$  are both positive, typical type II heterojunctions are formed at the BVO/ $FeMO_x$  interfaces. Importantly, this configuration is ideal for enhancing the PEC performance of photoanodes because the photogenerated holes in the VB of the BVO layer are readily transported to the VB of the  $FeMO_x$  layer, and the corresponding photogenerated electrons are effectively maintained in the CB of the BVO. Furthermore, the p-n heterojunction induces a built-in electric field, which assists in the transport and separation of the photogenerated charges at the heterojunction, accelerating the holes towards the  $FeMO_x$  layer and the electrons towards the FTO substrate. Fig. 6C and D show the qualitative interfacial band alignment of BVO/ $FeMO_x$  heterojunctions (corrected with Kraut's method) under AM

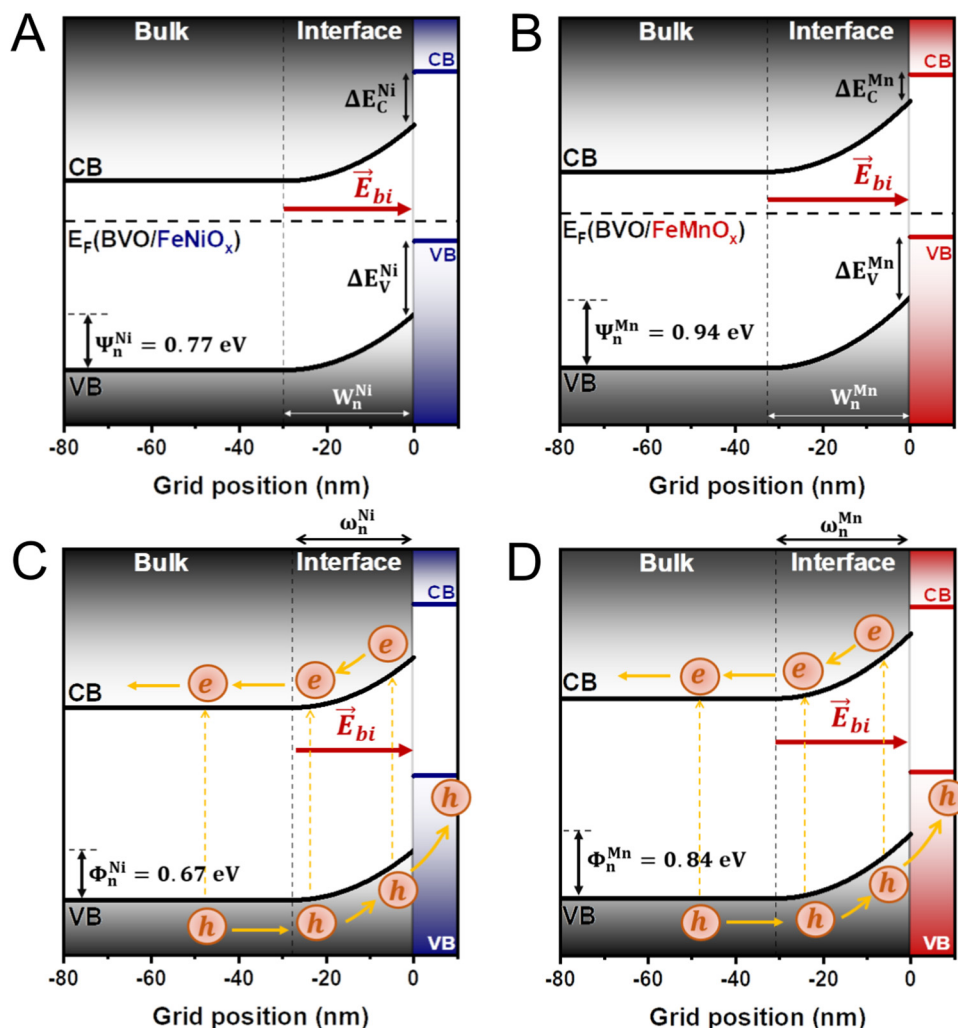


Fig. 6 Interfacial band alignment obtained from Kraut's method combined with the classical band model under dark conditions for (A) BVO/ $FeNiO_x$  and (B) BVO/ $FeMnO_x$  films, and under AM 1.5 illumination for (C) BVO/ $FeNiO_x$  and (D) BVO/ $FeMnO_x$  films. Notice that due to band flattening effect, the energy drops and lengths upon illumination ( $\Phi_n^M$  and  $\omega_n^M$ ) are significantly lower than that under dark conditions ( $\Psi_n^M$  and  $W_n^M$ ), where  $M = Ni, Mn$ .



1.5G illumination, clearly indicating the band flattening effect. In this case, although the built-in electric field is considerably weakened, the  $\Delta E_C^{Ni}$  and  $\Delta E_C^{Mn}$  potential barriers inhibit the flow of electrons from the CB of the BVO to the CB of the FeMO<sub>x</sub> layer (since  $\Delta E_C^{Ni,Mn}/e \gg kT/e$  at room temperature), ensuring that these electrons are transported to the FTO substrate. Conclusively, our results show that the BVO/FeMnO<sub>x</sub> heterojunction presents a more intense built-in electric field (indicated by a large SCR) than the BVO/FeNiO<sub>x</sub> photoanode, suggesting a superior PEC performance which is confirmed by our PEC experiments.

In summary, the simulated interfacial band alignment of our p–n heterojunctions (with or without illumination) show that the deposition of FeMO<sub>x</sub> (M = Ni, Mn) ultrathin layers can induce significant bending of the BVO energy bands, indicating that in addition to acting as efficient cocatalysts – reducing overpotential for the water oxidation reaction and considerably lowering the resistance at the photoanode/electrolyte interface – they also promote enhanced separation and transport of charges due to the induction of local p–n heterojunctions on the surface of BVO. Interestingly, we showed that the interfacial band alignment using flat diagrams before equilibrium produces misleading results, contradicting the evaluated PEC performance of our photoanodes. In contrast, the combination of Kraut's method with the classical band bending model clearly demonstrates the formation of type II heterojunctions at the BVO/FeMO<sub>x</sub> interface, also indicating the presence of a built-in electric field that accelerates the photogenerated charges in the ideal direction for PEC applications. Therefore, this model justifies the higher photocurrent densities and durability of the heterostructured films, also suggesting the reasons for the higher PEC performance of our new BVO/FeMnO<sub>x</sub> heterojunction compared to conventional FeNiO<sub>x</sub> surface-modified BVO photoanode. Notably, our findings introduce FeMnO<sub>x</sub> as a potential cocatalyst for surface modification of n-type semiconductors applied in solar water-splitting devices for converting sunlight into storable chemical fuels.

## Conclusions

In summary, bare BiVO<sub>4</sub> and BiVO<sub>4</sub>/FeMO<sub>x</sub> (M = Ni, Mn) heterojunctions were successfully synthesized by magnetron sputtering deposition using a low-cost ceramic target. Photocurrent densities and onset potentials of bare BiVO<sub>4</sub> film were significantly improved after the deposition of amorphous bimetallic oxides due to the synergistic effect between p–n heterojunction formation and the cocatalyst effect. The BVO/FeMnO<sub>x</sub> film exhibited the highest PEC performance among the studied heterojunctions, with a photocurrent density of 1.25 mA cm<sup>-2</sup> vs. 1.23 V vs. RHE and the highest chemical stability at 1.23 V vs. RHE, thereby suggesting that deposition of Mn-based cocatalysts is very promising for PEC applications. A combination of electronic properties, optical activity, and band diagrams under dark conditions was used to elucidate the improved PEC performance of the heterojunctions.

Our analyses of band diagrams after equilibrium unambiguously revealed that the BVO/FeMnO<sub>x</sub> heterojunction presents a superior PEC performance due to the more intense built-in electric field induced at the p–n interface compared to BVO/FeNiO<sub>x</sub>. Essentially, our study provides a viable technique for producing photocatalytic heterojunction systems based on metal oxide semiconductor films surface-modified with cocatalysts and introduces simple tools for investigating interface effects on photoinduced charge carrier pathways for PEC applications.

## Conflicts of interest

There are no conflicts of interest to declare.

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